In situ STXM investigations of pentacene-based OFETs during operation

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Ultrathin pentacene-based organic field-effect transistors (OFETs) on commercially available silicon nitride membranes suitable for transmission X-ray experiments are demonstrated. The devices produced by high-vacuum deposition show excellent electronic performance ($\mu = 0.6 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$, $I_{on/off} = 10^4$). STXM-experiments recorded with the PolLux microspectroscope correlate structural and electronic properties at highest spatial and spectral resolution while the OFET is operated. Local NEXAFS spectra are used to analyze the different orientations of the pentacene nanocrystals. Spectral changes due to modifications in the electronic structure during OFET operation can hardly be detected with the current setup.

Introduction

Remarkably improved performance by research efforts of uncounted groups opened the way to commercial applications of organic semiconductors.1–3 Based on a better understanding and improved control of the film growth, organic semiconductor devices have reached the performance of amorphous silicon products.4,5 Nevertheless, the comparison of polycrystalline thin film devices to the electronic performance of devices based on organic single crystals shows that there is still plenty of room for further improvement.4,6 It is well established that the polycrystalline morphology affects the transport characteristics in organic thin film devices. However, imaging techniques like, e.g., atomic-force microscopy (AFM) can hardly offer insight into individual nano- or microdomains.

In this paper we report on the investigation of thin film organic field-effect transistors (OFETs) with emphasis on the correlation of morphological and electronic properties using scanning transmission soft X-ray microspectroscopy (STXM). Due to the limited penetration depth of soft X-rays ultrathin film samples are required. Therefore, we prepared our OFET devices on commercially available ultrathin Si3N4 membranes. This in contrast to many other pentacene-based OFETs reported in the literature where thin film dielectrics on solid substrate crystals are used.5,8–10

STXM relies on the near-edge X-ray absorption fine structure (NEXAFS/XANES) contrast by probing the unoccupied states when a focused X-ray beam is raster-scanned across the sample. Several contrast mechanisms, e.g., thickness modulations or chemical and elemental contrast due to photon energy dependent absorption, are suitable to record an image of a thin film sample. In the present devices only carbon K-edge absorption needs to be considered. At energies well above the K absorption edge of carbon (>318 eV) the difference in absorption intensities is purely based on thickness and density variations within the film. At the respective absorption resonances, the linear absorption dichroism may be applied to deduce the molecular orientation.11

Besides the characterization of the transport properties and the microscopic imaging of thus prepared OFETs, we are considering the possibility of identifying changes in the electronic properties while the OFET is operated. Applying a gate voltage and driving a current through the device will induce changes in the electronic levels, which should be accessible by means of core-electron excitation spectroscopy.

Experimental

The thin film devices were prepared by subsequent deposition of the different materials (pentacene, gold contacts) through a shadow mask under high-vacuum conditions ($p < 1 \times 10^{-6}$ mbar) in the so-called top-contact geometry [Fig. 1(a)]. As dielectric, commercially available Si3N4 membranes (thickness: 100 nm; membrane size: 1 $\times$ 1 mm²; supplier: Silson Ltd., UK) were used. On the backside of the dielectric an aluminium film with a nominal thickness of 20 nm was deposited at a rate of 1 Å s⁻¹ as gate contact.

Pentacene purchased from Sigma Aldrich and resublimed twice prior to film deposition was used as active organic semiconductor material. Nominally 30 nm thick pentacene films were grown at a rate of 0.1 Å s⁻¹ at 333 K as controlled by a quartz microbalance (base pressure: $<$5$ \times$ 10⁻⁷ mbar). After evaporation the samples were held at 333 K for another two hours and stored in vacuum over night to ensure the formation of a high quality pentacene film. The devices have a channel width $W =$ 250 μm and a length $L =$ 40 μm ($W/L$ ratio: 6.25) or $L =$ 20 mm ($W/L$ ratio: 12.5), respectively.

We have chosen Au top electrodes (thickness 30 nm) due to their low injection barrier12 to achieve maximum electronic performance. Thus, the overall device thickness is thin enough to allow sufficiently high transmittance for soft X-rays which are used for high spatial resolution electron microspectroscopy in STXM. The analysis of metal–insulator–metal (MIM)-structure
devices revealed an average dielectric strength of 12.3 MV cm\(^{-1}\), a dielectric constant of \(\varepsilon_r = 9.89\) and an area capacitance of 87.5 nF cm\(^{-2}\) for our silicon nitride dielectric. For device operation a negative gate voltage \((V_{GS} = -10\) V\) was applied. The electrical characteristics of the devices were recorded with an Agilent 4156C parameter analyser under ambient conditions at room temperature.

Our STXM experiments were performed at the PolLux STXM at the Paul Scherrer Institut (PSI, Villigen, Switzerland), which has proven spatial resolutions as low as 20 nm.\(^{13-15}\) Zone-plate focusing is used to achieve 40 nm lateral resolution in routine operation.\(^{13}\) The photon energy dependent absorption signal \((I/I_0)\) is measured by a conventional photomultiplier detector mounted behind the sample from comparison of the transmitted intensity \((I)\) with the incoming photon flux \((I_0)\).

**Results**

The electrical transfer characteristics of a selected device are shown in Fig. 1(b). A maximum gate current of 48 pA (filled diamonds, leakage at \(U_{GS} = -10\) V) was obtained. Extracted from the saturation regime of the \(J_{DS}\) vs. \(V_{GS}\) plot, also included in Fig. 1(b) (open squares), the charge carrier mobility was determined to be 0.35 cm\(^2\) V\(^{-1}\) s\(^{-1}\) and the threshold voltage as \(-2.3\) V. In addition, our devices exhibit a subthreshold slope of 0.3 V dec\(^{-1}\) and the on/off current ratio is as large as \(10^6\). Thus, the electronic properties of our devices are compatible with recently published data of state-of-the-art pentacene OFETs.\(^{16}\)

Two STXM micrographs, presented in Fig. 2, show an area of the pentacene film within the channel of the source and drain electrodes. A photon energy of 320 eV was used to record the image of Fig. 2(a). At this energy no particular spectral features appear for pentacene. Thus, the transmitted intensity reflects the thickness dependence and the modulation in the image is due to morphology variations in the film. The image recorded at 285.8 eV [Fig. 2(b)], which corresponds to the main C 1s absorption resonance of pentacene,\(^{17}\) shows higher contrast compared to Fig. 2(a). A relatively homogenous size distribution with an average diameter of the individual pentacene grains of around 250 nm was found. It is well known that the actual size distribution and homogeneity of the organic film strongly depend on the preparation conditions and strongly affect the electronic performance of the devices, e.g., the charge carrier mobility, which is discussed controversially in the current literature.\(^{18,19}\)

In order to explore the intensity differences in more detail, local NEXAFS spectra from the two adjacent grains marked A and B in Fig. 2(b) were recorded. The extracted spectra shown in Fig. 2(c) were normalized to the pre- (280 eV) and post-absorption edges (320 eV) according to standard procedures.\(^{13}\) Simplified, the resonances originate from the excitation of a localized core electron into unoccupied delocalized molecular orbitals (\(\pi^*\)) or quasi-bound vacuum states (\(\sigma^*\)). The absorption signal strongly depends on the polarization of the incident photons with respect to the unoccupied molecular orbitals.\(^{11}\) In C K-NEXAFS of pentacene, the most intense and sharp \(\pi^*\)-resonances may be used to derive the molecular orientation. The NEXAFS resonances of pentacene have been discussed in several publications and shall not be considered here.\(^{13,20,21}\) For the present discussion only the intensity differences of the \(\pi^*\)-resonances in the energy range from 282.5 to 289 eV are relevant. The intensity in the two representative grains differs by more than a factor of 2 in the normalized spectra which is unambiguously attributed to differences in the respective grain orientations.
For a more detailed analysis of the dichroism a rotational device (see Hernández-Cruz et al.\textsuperscript{23}) was implemented into the PolLux microspectroscope. X-Ray micrographs recorded at different azimuthal orientations ($\alpha = 0^\circ$, $25^\circ$, $50^\circ$) are presented in Fig. 3(a)–(c). Again a polycrystalline film consisting of coalescing grains with differently orientated molecular unit cells is found. Within the presented images two representative areas are highlighted. In these highlighted areas even a contrast reversal for selected grains can be easily observed while the specimen is rotated.

The determination of their absolute orientations is not straightforward, since no preferential azimuthal angle is accessible from the present data and, in addition, the polarization of the incoming radiation cannot be rotated in the present STXM setup to explore the full angular dependence. However, additional AFM investigations of monolayer films on the silicon nitride substrates (not shown here) revealed a monolayer film thickness of approximately 1.6 nm that perfectly fits to the length of a single pentacene molecule. Therefore, we can conclude that the pentacene molecules are standing upright on our silicon nitride substrate (or only slightly deviating from perpendicular orientation). In addition, if we assume the observed thin film phase found for pentacene on silicon dioxide, each unit cell contains two molecules. Unfortunately it is not possible to determine the exact angle that is spanned by the molecular planes of these two molecules within the unit cell by STXM microscopy. Assuming a perpendicular (or almost perpendicular) long-axis molecular orientation in grain B in Fig. 2(b), we estimated a relative difference of azimuthal rotation of about 30 degrees for grain A. Exact determination would require additional experiments with significant out-of-plane polarization of the X-rays (with respect to the sample substrate), which cannot be performed in the present PolLux-STXM setup.

The third aspect of this paper concerns the changes in the electronic structure while the OFET devices are operated. It is well established that the majority of the charge carriers are formed in the present PolLux-STXM setup.

To get access to this accumulation layer and to improve the signal to background ratio ultrathin pentacene films are essential. There-
conventional AFM topography analysis. Standard X-ray absorption investigations of thin pentacene films report on average tilt angles of 11 degrees with respect to the surface normal for pentacene on SiO$_2$ substrates.$^{24}$ For metal substrates the much larger interaction at the metal–pentacene interface leads to coplanar orientation of the aromatic system which relaxes to bulk-like orientation similar to SiO$_2$.$^{17}$ We should, however, point out that conventional NEXAFS averages over areas of about 1 mm$^2$ and may therefore not resolve orientation inhomogeneities as in STXM. Our present studies indicate that the grains with different azimuthal orientations may affect the transport properties in the ultrathin polycrystalline films.

Finally, we would like to address the aspect, why our present NEXAFS studies cannot detect changes in the electronic structure while the OFET is operated. Additional charges on the pentacene molecules would implement changes in the molecular orbitals, i.e., one expects either differential energetic shifts of the NEXAFS resonances or variations in the NEXAFS intensities due to additional charging (accumulation of holes) of the molecular orbitals. Moreover, a polarization within the upright standing pentacene molecules is induced by the electric field of the gate bias. This polarization is expected to lead to an energetic shift of the involved HOMO and LUMO electronic states.

Several aspects may be considered to explain the missing spectral changes in the present experiments. First, calculation of the area charge $Q$ within the channel of our devices revealed that only about one percent of the pentacene molecules carries electric charge.$^{28}$ Second, as in STXM the transmitted intensity is detected, it is mainly sensitive to the bulk signal of the pentacene film. However, the majority of the charge transport takes place within the first few nanometres of the film.$^{29,26}$ Thus, signals originating from the pentacene–dielectric interface are recorded against a relatively large background signal originating from photons, that were not absorbed within the film, while the major absorption stems from the bulk material. A signal change (intensity damping or spectral shift) originating from 10–20 percent of the molecules within the whole film should be expected.$^{‡}$ Another argument for the missing spectral changes during on/off-operation may be the insensitivity of the core-excitation due to very short-lived excitonic-states in polarized molecules. However, since the excitations occur on the timescale of $10^{-15}$ s, we do not expect such ultrafast relaxation processes. More probably is a potential Fermi-level pinning that has been discussed for the pentacene–SiO$_2$ interface.$^{30}$ In that case, no spectral changes at the low-energy onset of the NEXAFS spectra are to be expected.

Future developments may, however, improve the thin-film sensitivity of STXM, in particular when electron yield detection using channeltron detectors is employed.$^{14}$ Pentacene-based OFETs with film thicknesses of 5 nm and good device characteristics have successfully been prepared. Such devices may be used to finally observe local modifications to the electronic structure if no other than the above mentioned effects apply.

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References


‡ This estimation is based on an average film thickness of about 4 monolayers and, in addition, dichroic effects, i.e. dependence of absorption on azimuthal orientations of the individual grains.